Press Release

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Nanonex
Engine for Nanotechnology ™

University of Minnesota purchases Nanonex Advanced Nanoimprint Tool NX-B200

Princeton NJ, Jul. 23, 2008: Nanonex Corporation, the inventor and world's leading provider in nanoimprint lithography solutions with the longest history, announces the purchase of a Nanonex NX-B200 system by the University of Minnesota, Minneapolis, MN.

The Nanonex NX-B200 purchased by the Nanofabrication Center at University of Minnesota is a compact, cost-effective and versatile sub-10 nm resolution nanoimprint tool, utilizing Nanonex's patented Air Cushion Press™ technology to provide unsurpassed uniformity and yield over the entire substrate. The NX-B200 also incorporates a fully flexible Smart Sample Holder that accommodates any size of substrate or mask up to the maximum capability including arbitrary shaped geometries.

The NX-B200 was purchased by Steve Campbell, Director of the Nanofabrication Center. Nanonex is proud to support the leading edge research of the Nanofabrication Center, which is a multi-user facility and a partner in the National Nanotechnology Infrastructure Network (NNIN).

About Nanonex Corporation
Nanonex is the inventor of "nanoimprint lithography", the world's first nanoimprint lithography company, and the world's leading provider of nanoimprint solutions that include equipment, masks, resists and processes. Nanonex's patented and proprietary nanoimprint lithography (NIL) solutions and Air-Cushion Press™ can manufacture 3D nanostructures with sub-5 nm resolution, large-area uniformity, accurate overlay alignment, high throughput, and low cost. Nanonex NIL solutions have been adopted by a broad spectrum of industry applications, such as optical devices, data storage, displays, light emitting diodes, semiconductor ICs, biotech, chemical synthesis, and advanced materials. Nanonex has over 100 customers and an installed base of more than 40 tools world-wide. Visit www.nanonex.com for additional information.